

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

12/6/02

In re Appln. Of:

YOKOYAMA

DEC - 4 2032

Serial No.:

08/992,767

TECHNOLOGY CELLIER 2800

Filed:

December 17, 1997

For:

CONTACT STRUCTURE IN SEMICONDUCTOR....

Group:

2814

Examiner:

DOUGLAS A. WILLE

DOCKET: NEC 19654 CON

BOX RCE

Assistant Commissioner of Patents

Washington, D.C. 20231

AMENDMENT G WITH RCE

Dear Sir:

This Amendment is being filed in response to the Final Action mailed August 26, 2002.

A Request for Continued Examination (RCE) accompanies this Amendment.

Please amend the Application as follows:

12/03/2002 AMONDAF1 00000104 08992767

01 FC:1202

100.00 CH

8.00 OP

IN THE CLAIMS:

Please amend claims 11 and 20, to read as follows:

and a small-diameter contact hole formed to penetrate through an insulator film formed on a semiconductor substrate to reach said semiconductor substrate, each of said large-diameter contact hole and said small-diameter contact hole having a constant-diameter portion formed on a lower portion thereof, and a funnel-shaped portion formed on an upper portion thereof to open or spread upward, said small-diameter contact hole being completely filled with a plug of a refractory conductive material which contacts said semiconductor substrate, and said large-diameter contact hole being partly filled by said refractory conductive material which covers a 12/03/2002 ANDROFT 00000103 08992767

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02 FC:1201 03 FC:1202

168.00 OP